Supporting Information

Defect-rich Fe doped NiS/MoS₂ heterostructured ultrathin nanosheets

for efficient overall water splitting

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1. Materials

Sodium molybdate dihydrate (Na₂MoO₄·2H₂O, 99.0%), nickle nitrate hexahydrate [Ni(NO₃)2·6H₂O, 99.0%], Ferric nitrate nonahydrate [Fe(NO₃)₃·9H₂O, 99.0%], Nafion solution (5 wt%), N,N-dimethylformamide (DMF), Potassium hydroxide (KOH, 99.0%) and ethanol were purchased from Sinopharm Chemical Reagent Co. Ltd. 4,4-Bipyridine (C₁₀H₈N₂, 98%) and Pluronic® F-127 were purchased from Aladdin Industrial Corporation (Shanghai, China). All the reagents used in the experiment were of analytical grade and used without further purification.

2. Characterization

X-ray diffraction (XRD, PANalytical B.V. Empyrean Cu Ka radiation) was used to identify the crystal structure of prepared samples. Scanning electron microscopy (SEM, HITACHI SU8000) and transmission electron microscopy (TEM, JEOL JEM-2200FS) were utilized to investigate the morphology of samples. X-ray photoelectron spectroscopy (XPS) data were collected using ESCALAB 250 spectrometer with a monochromatic X-ray source with Al Kα excitation (1486.6 eV) under ultrahigh vacuum.

3. Electrode preparation and electrochemical measurement

Electrochemical measurements were performed with an electrochemical workstation (CHI 760E, CH Instruments Inc.) in 1 mol L⁻¹ KOH aqueous solution. Saturated Calomel Electrode (SCE) and graphite rod were used as the reference and counter electrode, respectively. Typically, 4 mg of the catalyst powder was dispersed in 1mL of 50 vol % water and 50 vol % N,N-Dimethylformamide (DMF) mixed solvent, and the mixture was sonicated for 30 min. Then, 10 μ L of the above solution was drop-cast onto the surface of a glassy carbon (GC) electrode. All the potential values were converted with respect to a reversible hydrogen electrode (RHE). Polarization curves were acquired under a potential sweep rate of 5 mV s⁻¹. Stability tests were performed in a potential range of -0.5 ~ 0 V for HER and 1.2 ~ 1.7 V for OER with a potential sweep rate of 150 mV s⁻¹ for 1000 cycles. Current-time responses were operated by chronoamperometric measurements for 60000 s. The electrochemical

impedance spectroscopy (EIS) was carried out in the range from 100 KHz to 0.1 Hz with an AC amplitude of 5 mV. All the current density presented here was normalized to the geometrical area (0.0707 cm²) of glassy carbon electrode with 95% iR correction. 4. synthetic method for control samples: Fe-doped NiS and Fe-doped MoS₂

9 mmol Ni(NO₃)₂·6H₂O, 5 mmol 4,4-bipyridine and 1 mmol Fe(NO₃)₃·9H₂O were grinded to form evenly powder denoted as precursor A. 9 mmol Na₂MoO₄, 5 mmol 4,4bipyridine and 1 mmol Fe(NO₃)₃·9H₂O were grinded to form evenly powder denoted as precursor B. Each of the above precursors was transferred into a corundum boat located at the center of a tubular furnace. Another corundum boat containing S powder was then placed in the upstream of precursor. Under a ramp rate of 3 °C min⁻¹, the tubular furnace was heated to 500 °C in N₂ atmosphere, and this temperature was maintained for 1h. The resultant products are denoted as Fe-doped NiS and Fe-doped MoS₂, respectively.

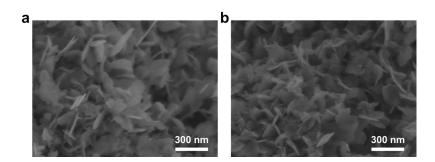


Fig. S1 SEM images of (a) 0.05Fe-Ni/Mo MOF and (b) 0.2Fe-Ni/Mo MOF

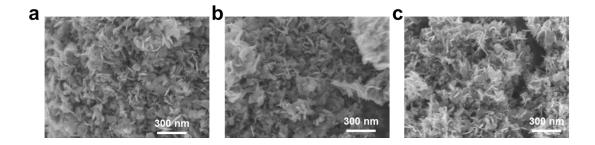


Fig. S2 SEM images of (a) NiS/MoS₂, (b) 0.05Fe-NiS/MoS₂ and (c) 0.2Fe-NiS/MoS₂

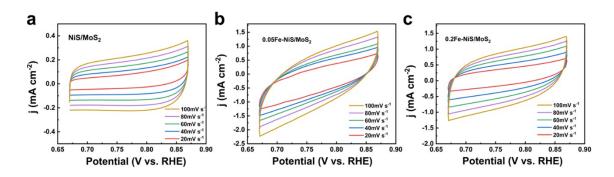


Fig. S3 CV curves of (a) NiS/MoS₂, (b) 0.05Fe-NiS/MoS₂ and (c) 0.2Fe-NiS/MoS₂ under different scan rates.

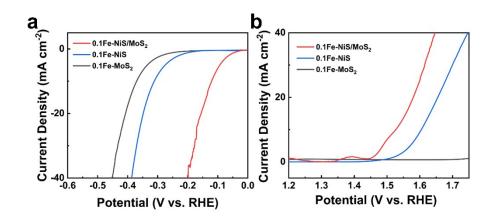


Fig. S4 HER (a) / OER (b) performance comparison of 0.1Fe-NiS/MoS₂ with Fe-doped NiS and Fe-doped MoS₂

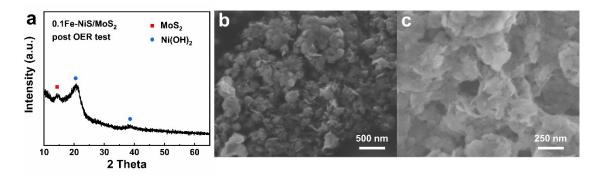


Fig. S5 XRD pattern (a) and SEM images (b, c) of 0.1Fe-NiS/MoS₂ post 1000 cycles OER test.

| | | 1 | |
|----------|-----------------------------|----------------------------|----------------------------|
| elements | 0.05Fe-NiS/MoS ₂ | 0.1Fe-NiS/MoS ₂ | 0.2Fe-NiS/MoS ₂ |
| Fe atom% | 2.01 | 5.09 | 10.38 |
| Ni atom% | 41.26 | 45.89 | 39.73 |
| Mo atom% | 56.73 | 49.02 | 49.89 |

Table S1. The ICP-AES result for samples with different Fe amount

Table S2. HER/OER activity comparison with the recently reported Ni/Mo based sulfides.

| Samples/substrates | HER η ₁₀ (mV) | HER Tafel | OER η ₁₀ (mV) | OER Tafel | |
|---|-----------------------------|-------------------------|-----------------------------|-------------------------|-----------|
| | | slope | | slope | reference |
| | | (mV dec ⁻¹) | | (mV dec ⁻¹) | |
| NiS/MoS ₂ /C (GC) | 117 | 58 | - | - | 1 |
| MoS ₂ /rGO/NiS (GC) | 169 | 91.6 | - | - | 2 |
| MoS ₂ NiS MoO ₃ | 91 | 54.5 | - | - | 3 |
| NiS/MoS ₂ (CC) | 174 | 70.2 | - | - | 4 |
| MoS ₂ /NiS (GC) | 244 | 97 | 350 | 108 | 5 |
| Fe/C-doped- | 188 | 95 | 270 | 66 | 6 |
| MoS ₂ /Ni ₃ S ₂ (GC) | | | 270 | | |
| NiS ₂ /MoS ₂ (GC) | 135 | 82 | 293 | 102.3 | 7 |
| NiS ₂ /MoS ₂ (CC) | 91 | 57.2 | 362 (ŋ ₅₀) | 117.3 | 8 |
| 0.1Fe-NiS/MoS ₂ (GC) | 120 | 69.0 | 297 | 54.7 | This work |

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